



## Taek-Sung KIM

Affiliated Counsel

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### Practice Area

- Intellectual Property

### Experience

- Affiliated Counsel, Lee International IP & Law (2023~Present)
- Director of Operations, KAIST-Hwaseong City Science Hub, Enterprise Development Center (2022~Present)
- Deputy Director, HA & HA IP Law Firm (2017~2021)
- Patent General Manager/Managing Director, Samsung Electronics DS IP Team (2011~2016)
- Head, Samsung Electronics DS IP Procurement Group (2007)
- Member, Patent Dispute & Legal Advisory Committee, Korea Electronics Association (2005~2017)
- Mediator for IP & Technology, California State Mediation Association (2003)
- Trainee, Cushman Darby & Cushman law firm, USA (1996)
- Patent Trainee, Intellectual Property Department of Samsung Electronics D.C. Office (1995~1996)
- Manager, Licensing Group, Intellectual Property Center, Samsung Electronics (1993~1999)
- Principal Researcher, Avionics Research Center, Samsung Advanced Institute of Technology (1988~1992)

## Education

- Kuhnen Wacker IP Training Program (2012)
- Samsung VP Training Course (2008~2009)
- University of New Hampshire - Franklin Pierce IP Law Center, U.S. (J.D., M.I.P., 2004)
- CD&C Summer IP Training Program (1996)
- Samsung Washington DC Office IP Training Program (1995)
- Kyungpook National University (B.A., Electric Engineering, 1988)

## Qualifications

- Admitted to the Bar, Massachusetts (2004)

## Publications / Presentations

- Co-author, Studies on U.S. Patent Cases Parts 1, 2, and 3, American Patent Law Institute (2013, 2017, 2022)
- Study on the Need to Raise the Standards for Determining Non-obviousness in U.S. Patents, Inventions and Patents (December 2004)

## Awards & Recognition

- Citation from the Vice Chairman of Samsung Electronics (2012)
- Citation from the Presidential Council on Intellectual Property (2011)
- Citation from the Minister of Knowledge Economy (2008)

## Etc

- Languages: Korean, English

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